

Device Research Conference 2026

University of Michigan, Ann Arbor – June 21-24, 2026

Full Program — Talk Titles, Presenters & Affiliations

Talk durations (incl. Q&A): Plenary [PL] 60 min | Keynote [KN] 40 min | Invited [INV] 30 min | Contributed 20 min | [STU] = student presenter | [LN] = Late News | [SC] = Short Course

Sunday, June 21

YP/WiED Forum: the Future of Semiconductors in the AI Era

Chairs: Yuxuan Cosmi Lin (Texas A&M; University), Raisul Islam (Purdue University), Ying-Chen Daphne Chen (Arizona State University)
Michigan League - Vandenberg, 2nd floor

8:30 AM **Welcome and Introduction**

Session 1: Technical Presentations

8:40 AM **Ying-Chen Daphne Chen** *Arizona State University*

9:05 AM **Jiarui Gong** *Texas A&M; University*

9:30 AM **Esmat Farzana** *Iowa State University*

9:55 AM **Raisul Islam** *Purdue University*

10:15 AM **Coffee Break**

Session 2: Panel Discussion – Developing a successful career in the new era of microelectronics and artificial intelligence

10:45 AM **Moderator:** Raisul Islam

– 11:45 AM **Panelists:** Ying-Chen Daphne Chen (Arizona State University), Jiarui Gong (Texas A&M; University), Esmat Farzana (Iowa State University), Austin Hickman (Soctera), Iuliana Radu (TSMC)

11:45 AM **Lunch Break**

10:00 AM Registration Opens

Michigan League - Concourse

Short Course: "Best Practices for Reporting on Electronic Devices" | Organizers: Theresia Knobloch, Michiel van Setten | Michigan League - Vandenberg, 2nd floor

1:00 PM **[SC] Aaron Franklin** *Duke University*
Best Practices in Reporting and Benchmarking Performance of 2D Transistors: A Scaling and Contacts Story
Chair: Theresia Knobloch

1:50 PM **[SC] Tibor Grasser** *TU Wien*
Reliability Issues in Devices Based on Emerging Materials

2:40 PM **Coffee Break**
Michigan League - Michigan Room, 2nd floor

3:00 PM **[SC] Adrian Chasin** *IMEC*
IGZO Thin-Film Transistor Reliability: the Last Roadblock for Memory Applications
Chair: Michiel van Setten

3:50 PM **[SC] Becky Peterson** *University of Michigan*
TFT Performance

4:40 PM **Coffee Break**
Michigan League - Michigan Room, 2nd floor

5:30 PM Registration Closes

6:00 PM **DRC Welcome Reception**
Michigan League - Ballroom, 2nd floor

Monday, June 22

8:00 AM Registration Opens
Michigan League - Concourse

Opening

9:00 AM **[Opening] Tania Roy** *DRC General Chair*
Introduction and Conference Welcome
Lydia Mendelssohn Theatre, Michigan League, 2nd floor

Plenary 1

9:20 AM **[PL] Chair: Eilam Yalon | Mark Lundstrom** *Purdue University*
Lessons from 45 Years of Research Exploring Carrier Transport in Semiconductor Devices
Lydia Mendelssohn Theatre, Michigan League, 2nd floor

10:20 AM **Coffee Break**
Michigan League – Michigan Room, 2nd floor

Plenary 2

10:40 AM **[PL] Chair: Eilam Yalon | Frank Koppens** *ICFO*
Optoelectronic devices with 2D moiré materials
Lydia Mendelssohn Theatre, Michigan League, 2nd floor

11:40 AM **Lunch Break**

Luncheon Talk

12:00 PM **[Talk] Chris Olsen** *Applied Materials*
The Innovation Multiplier: Collaboration at the Intersections of Device, Process, and Hardware
Michigan League – Vandenberg, 2nd floor (overflow in Concourse area)

12:45 PM **Break**

Award Session 1

Michigan League - Hussey, 2nd floor

Award Session 2

Michigan League - Vandenberg, 2nd floor

Award Session 3

Michigan League - Koessler Room, 3rd floor

1:00 PM
[STU] Yinxuan Zhu *Ohio State*
Design and Demonstration of Scaled Ultra-Wide Bandgap AlGa_N Polarization-graded FETs with Current Gain Cutoff Frequency (f_T) Above 85 GHz

1:00 PM
[STU] Jeongwoo Kim *Cornell*
10 W/mm X-band AlN XHEMTs with 17-nm GaN channel

1:00 PM
[STU] Pietro Rinaudo *imec & KU Leuven*
Impact of IGZO composition on sub-gap defects and hydrogen resiliency during PBTI in back-gated TFT

1:20 PM
[STU] Ruixin Bai *U Wisconsin-Madison*
Demonstration of record (for Ultra-Wide Band Gap) output power of 2.7 W/mm at 20 GHz with Al_{0.65}Ga_{0.35}N channel RF HEMTs

1:20 PM
[STU] Sumi Lee *Purdue*
Activation-Energy-Dependent 1/f Noise in Scaled ALD IGZO TFTs via Temperature-Dependent Dutta-Horn Analysis

1:20 PM
[STU] Rivka-Galya Nir-Harwood *Technion*
Exploring Non-Destructive Sub-Threshold Readout of Selector-Only Memory Devices

1:40 PM
[STU] Seungheon Shin *Ohio State*
High Breakdown Field Multi-kV UWBG AlGa_N Transistors for Power Switching and High-Voltage RF Applications

1:40 PM
[STU] Jiwon Ma *Yonsei U*
Vertically Stacked NMOS Inverter Based on Multi-layer WS₂ Formed via Multiple Wet-Transfers of Monolayer WS₂

1:40 PM
[STU] Shafin Bin Hamid *UT Austin*
Comparison of Ferrimagnetic and Antiferromagnetic Tunnel Junctions for High-Speed Random Bitstream Generation

2:00 PM
[STU] Hsin Wei (Sheena) Huang *Cornell*
Waveguide vs. Quantum Well Electroluminescence in High-Current-Density Deep-UV AlGa_N Heterostructure Diodes on Bulk AlN

2:00 PM
[STU] Madhav Ramesh *Cornell*
Large barrier height ultrawide bandgap AlGa_N Schottky barrier diodes

2:00 PM
[STU] Utkarsh Misra *UT Austin*
Calcium-Regulated Plasticity in Graphene Artificial Synapses for Biomimetic Neuromorphic Computing

2:20 PM
[STU] Seungyun Lee *Seoul National U*
Demonstration of UWBG beta-Ga₂O₃ FeFETs with Large Memory Window under Harsh Temperatures (-175 to 105 C) using Al₂O₃/H₂O Gate Stack

2:20 PM
[STU] Khush Gohel *U Wisconsin-Madison*
3 kV Al-Rich AlGa_N HEMTs with >440 MW/cm² BFOM on Cost-Effective Sapphire Substrates

2:20 PM
[STU] Ziyang Gong *HKUST*
Self-aligned InGaAs FinFETs on Insulator by Selective Lateral Epitaxy

2:40 PM **Coffee Break**
Michigan League – Michigan Room, 2nd floor

Wide Band Gap & Power Devices 1 <i>Michigan League - Hussey, 2nd floor</i>	Focus Topic: 2D Materials 1 <i>Michigan League - Vandenberg, 2nd floor</i>	Focus Topic: Integration, Scaled Interconnects & Topological Materials <i>Michigan League - Koessler Room, 3rd floor</i>	Neuromorphic Computing & Memory Tech 1 <i>Michigan League - Kalamazoo, 2nd floor</i>
3:00 PM [KN] Grace Xing <i>Cornell University</i> Introducing AlN XHEMT - a new kid on the block	3:00 PM [KN] Aaron Franklin <i>Duke University</i> Understanding Contacts to 2D Semiconductors Considering Fab-relevant Technology Targets	3:00 PM [INV] Judy Cha <i>Cornell University</i> 1D Topological Semimetals for Next-Generation Electronics	3:00 PM [INV] Jean Anne Incorvia <i>UT Austin</i> Wafer-Scale SOT-MRAM for Neural Network Computation
3:40 PM Saurav Roy <i>NC State</i> Multi-kV Vertical FinFETs with Edge Dielectrics and Split Gates	3:40 PM Anil Adhikari <i>Notre Dame</i> CVD WSe ₂ p-MOSFETs with Nb:WS ₂ Contacts Formed by Low-Damage Plasma-Enhanced Atomic Layer Deposition	3:30 PM [INV] Chris Hinkle <i>Notre Dame</i> Novel Materials for Scaled Interconnects	3:30 PM [STU] RAVISH KUMAR RAJ <i>University of Southern Denmark</i> Multistate weighted Vortex Nano Oscillator based Neuron Device for Neuromorphic Computing
4:00 PM [INV] Samuel Graham <i>University of Maryland</i> Thermal Design of Ultra Wide Bandgap Electronics	4:00 PM [INV] Saptarshi Das <i>Penn State University</i> Scaling 2D CMOS - from Transistor to 3D Integrated Systems	4:00 PM [INV] Ritam Sarkar <i>imec</i> From GAA Nanosheets to Beyond-Moore: Unlocking the Future of FET Scaling in the Angstrom Era	3:50 PM [INV] Manuel Le Gallo <i>IBM Research Zurich</i> Deep Neural Network Inference with Analog In-Memory Computing
4:30 PM Yihao Zhuang <i>NTU Singapore</i> High-Power AlN/GaN-on-Si HEMTs Enabled by Top-Graded AlGa _N Back Barrier with Reduced Trapping and Parasitic Channels	4:30 PM Krishnendu Mukhopadhyay <i>Penn State</i> Integration of high-kappa gate dielectrics with 2D semiconductors via self-oxidizing vdW metal seed-layers		4:20 PM Suman Gora <i>IIT Roorkee, India</i> Impact of Ge Incorporation in SnO ₂ Mem-transistors on Their Characteristics for Optical Reservoir Computing and Synaptic Readout
4:50 PM Break			
5:30 PM Poster Session with Bar and Light Snacks <i>Michigan League - Ballroom, 2nd floor</i>			

Tuesday, June 23

7:30 AM Registration Opens
Michigan League - Concourse

Plenary 3

8:30 AM [PL] Chair: Eilam Yalon | Iuliana Radu *TSMC*
From materials to system: the path to performance
Lydia Mendelssohn Theatre, Michigan League, 2nd floor

9:30 AM Coffee Break
Michigan League – Michigan Room, 2nd floor

Wide Band Gap 2 <i>Michigan League - Hussey, 2nd floor</i>	2D Materials and Devices 2 <i>Michigan League - Vandenberg, 2nd floor</i>	Modeling and Simulations <i>Michigan League - Kalamazoo, 2nd floor</i>	Focus Topic: Memory and Neuromorphic Lab2Fab <i>Michigan League - Koessler Room, 3rd floor</i>
<p>9:50 AM [KN] Tomas Palacios <i>MIT</i> Lessons from a 20-Year Journey Translating III-Nitride and 2D Technologies from Lab to Fab (and to the Market...)</p>	<p>9:50 AM [INV] Gianluca Fiori <i>University of Pisa</i> 2D materials for next-generation devices and conformable electronics applications</p>	<p>9:50 AM [INV] Mathieu Luisier <i>ETH Zurich, Switzerland</i> Ab initio Modeling of 2D Materials and Devices: Role of the Surrounding Oxide Layers</p>	<p>9:50 AM [KN] Sayeef Salahuddin <i>UC Berkeley</i> Ferroelectricity in ultrathin binary oxides</p>
<p>10:30 AM Shumeng Yan <i>Nagoya U</i> Regrowth-Free Ex-Situ Mg-Diffused GaN-Based HBTs with High Gain of ~200</p>	<p>10:20 AM [STU] Sudarsan Majumder <i>IIT Madras</i> Non-Invasive Probing of Piezoresistivity in Low-Dimensional Materials Using Vibrating Channel Transistors</p>	<p>10:20 AM [STU] Sandeep Kumar <i>IIT Bhubaneswar, India</i> A Novel Unified Charge-Based Source-Referenced Model for Complementary FET Capturing the Quasi-Fermi-Driven Intersheet Coupling</p>	<p>10:30 AM [STU] Nishant Saini <i>imec & KU Leuven</i> On the Relation Between TDDB Lifetimes & Time-Zero Defect Noise</p>
<p>10:50 AM [INV] Maki Kushimoto <i>Nagoya University</i> Carrier Injection Challenges in High-Al-Composition Deep-UV Laser Diodes</p>	<p>10:40 AM [INV] Ageeth Bol <i>University of Michigan</i> Towards low-resistance p-type contacts to 2D TMDs using plasma-enhanced ALD</p>	<p>10:40 AM [INV] Rajib Rahman <i>UNSW Australia</i> Electrical control of single electron and hole spin qubits in silicon</p>	<p>10:50 AM [INV] Duk-Hyun Choe <i>Samsung Advanced Institute of Technology (SAIT)</i> Designing Oxide-Channel Ferroelectric Transistors for DRAM and NAND</p>
<p>11:20 AM Hitoshi Takane <i>Toyota Central R&D;</i> Distinct interface states in AlSiO/AlN/p-type GaN MOSFETs with c- and m-plane channel extracted by analytical drain current models</p>	<p>11:10 AM [STU] Quynh Phung <i>University of Stuttgart / University of Freiburg</i> Seed-Assisted Polarity Control of Flexible WSe2 Transistors and Demonstration of CMOS Inverters</p>	<p>11:10 AM [LN] TBD Late News</p>	<p>11:20 AM Louisa Schneider <i>Microchip Technology</i> Optimized Weight Assignments for In-Memory Computing e-Flash Cells Achieving 128 Discrete Target States with Elementary Charge Precision</p>

11:40 AM Lunch Break

Power Devices <i>Michigan League - Hussey, 2nd floor</i>	Focus Topic: 2D Materials and Devices 3 <i>Michigan League - Vandenberg, 2nd floor</i>	Focus Topic: Photonics 1 <i>Michigan League - Kalamazoo, 2nd floor</i>	Ferroelectric Devices <i>Michigan League - Koessler Room, 3rd floor</i>
<p>1:00 PM [INV] Kohei Sasaki <i>Novel Crystal Technology</i> Recent Progress in Gallium Oxide Power Devices</p>	<p>1:00 PM [INV] Adrian Chasin <i>imec, Belgium</i> IGZO Thin-Film Transistor Reliability: the Last Roadblock for Memory Applications</p>	<p>1:00 PM [INV] S. J. Ben Yoo <i>UC Davis</i> 3D Photonic-Electronic Integrated Devices and Circuits for Future Computing Systems</p>	<p>1:00 PM [INV] Kasidit Toprasertpong <i>University of Tokyo</i> Low-Voltage Ferroelectric Memory Enabled by Ultra-thin Hf1-xZrxO2: Scaling Benefits and Reliability Trade-Offs</p>
<p>1:30 PM [STU] Aditya Varma <i>MIT</i> First Demonstration of UWBG Al0.65Ga0.35N Monolithic Bidirectional Switch with RonSP = 13 mOhm cm2 and > 2.5 kV Breakdown Voltage</p>	<p>1:30 PM [INV] Huan Zhao <i>Oak Ridge National Laboratory</i> Nanoscale Magnetic Order and Skyrmions in 2D Materials Revealed by NV Magnetometry</p>	<p>1:30 PM [STU] Eitan Kaminski <i>Technion, Israel</i> Electro-Optically Tunable Arrayed Waveguide Grating on a Hybrid LN/SiN Platform</p>	<p>1:30 PM [INV] Halid Mulaosmanovic <i>GlobalFoundries</i> HfO2-based Ferroelectric Devices: from Lab to Fab</p>

1:50 PM
[INV] Geok Ing Ng
Nanyang Technological University
Lab-to-Fab of RF GaN in Singapore

2:00 PM
[LN] TBD
Late News

1:50 PM
[INV] Arka Majumdar
University of Washington
Photonic Integrated Circuits for Sensing and Computing

2:00 PM
[INV] John Heron
University of Michigan
Nanoscale Ferroelectric Transient Phenomena: From Models to Materials to Devices

2:20 PM
[INV] Jerry Comanescu
NIST
Toward Consistent Measurement Procedures for the Output and Transfer Characteristics of GaN HEMTs

2:20 PM
[INV] Yang Chai
Hong Kong Polytechnic University
Bioinspired in-sensor computing for artificial vision

2:20 PM
[STU] Shivali Agrawal
Cornell University
Monolithic integration of different wavelength LEDs using both sides of GaN substrates

2:30 PM
Mor Mordechai Dahan
Technion, Israel
Self-Referenced Ultrafast Non-Destructive FeRAM Readout with Enhanced Memory Window via Bipolar Integrated Charge

2:50 PM **Coffee Break**
Michigan League – Michigan Room, 2nd floor

Wide Band Gap 3
Michigan League - Hussey, 2nd floor

Focus Topic: BEOL FETs Lab2Fab
Michigan League - Vandenberg, 2nd floor

Neuromorphic Devices 2
Michigan League - Koessler Room, 3rd floor

3:00 PM
[INV] Seth Bank *UT Austin*
Digital Alloy Avalanche Photodiodes for Quantum Photonics

3:00 PM
[KN] Peide D. Ye *Purdue University*
Transport in Atomically Thin Amorphous Oxide Semiconductors

3:00 PM
[INV] Susan Fullerton Shirey *University of Pittsburgh*
Engineering electric double layers on two-dimensional crystal transistors

3:30 PM
Mateusz Hajdel *Institute of High Pressure Physics, Poland*
InGaN Inverted Laser Diodes operating in the Cryogenic Mg Freeze-Out Regime

3:40 PM
[STU] Meera Nandakumaran *University of Stuttgart, Germany*
Ultraviolet Ozone Treated Indium Gallium Zinc Oxide for Flexible Memristor Applications

3:30 PM
[STU] Samriddha Ray *Penn State University*
In-material meta-learning for event vision harnessing photo dynamics in LiInP2Se6

3:50 PM
[INV] Darrell Schlom *Cornell University*
Dawn of a Semiconductor with a 7 eV Bandgap: From Si-doped (AlxGa1-x)2O3 Films to initial Devices

4:00 PM
[INV] Kenji Nomura *UCSD*
Heterogeneous integrated 3D-FET for BEOL technology

3:50 PM
[INV] Yiyang Li *University of Michigan*
Thermodynamics of Phase Separation Enable Resistive Memory at Extreme Temperatures

4:20 PM
[INV] Travis Anderson *University of Florida*
GaN, AlN, and Ga2O3 Wafer Metrology and High Voltage Device Processing

4:30 PM
[LN] TBD
Late News

4:20 PM
[INV] Veeresh Deshpande *IIT Bombay*
BEOL compatible devices for neuromorphic computing: Integration to Circuit Design

4:50 PM **Break**

5:00 PM **Industry Session**
Session Chairs: Sriram Krishnamoorthy, Greg Pittner | Panelists: Gaurav Thareja (Applied Materials), Iuliana Radu (TSMC), John Barth (Synopsys)
Rackham Amphitheatre, 4th floor

5:30 PM Registration Closes

6:30 PM **Conference Banquet**
Rogel Ballroom, Michigan Union

8:00 PM **Award Ceremony & Valedictory**
Rogel Ballroom, Michigan Union

8:30 PM **Rump Session - Everything Switches: Sorting Fact from Fiction in Future Devices**
Organizers: Alwin Daus, Henryk Turski | Panelists: Thomas Mikolajick, Steven Koester, Debdeep Jena, Tomas Palacios | Rogel Ballroom, Michigan Union
Rogel Ballroom, Michigan Union

Wednesday, June 24

7:00 AM Registration Opens
Michigan League - Concourse

Joint EMC-DRC Plenary Session

8:20 AM **[PL] Rama Vasudevan** *Oak Ridge National Laboratory*
Nanomaterials synthesis and characterization advances enabled by AI-based operations: theory integration, data challenges and agentic futures
Lydia Mendelsohn Theater, Michigan League, 2nd floor

9:20 AM **Coffee Break**
Michigan League – Michigan Room, 2nd floor

Focus Topic: Wide Band Gap 4
Michigan League – Koessler Room, 3rd floor

Focus Topic: Photonics 2
Michigan League – Room 4, 1st floor

9:50 AM
[INV] Austin Hickman *Soctera*
11.7 W/mm Continuous Wave Output Power in X-Band AlN-Buffer HEMTs

9:50 AM
[INV] Ilya Goykhman *Hebrew University of Jerusalem*
Hybrid 2D photonic integration for light detection and manipulation on chip

10:20 AM
[STU] Ruixin Bai *University of Wisconsin-Madison*
Demonstration of high output power (3.4 W/mm) with 29% PAE in Ga-Polar AlGaIn/GaN HEMTs on sapphire at 94 GHz

10:20 AM
Huabin Yu *University of Michigan*
Low Threshold Electrically Pumped AlGaIn-QW Edge-Emitting Laser Diodes Operating at 298.5 nm

10:40 AM
Makoto Kasu *Saga University, Japan*
High frequency small signal characteristics of modulation-doped diamond FETs with the 157-nm T-shaped submicron-gate

10:40 AM
[INV] Stanley Cheung *NC State University*
Non-Volatility as a New Degree of Freedom in Hybrid III-V/Si Semiconductor Lasers

11:00 AM
[STU] Aias Asteris *Cornell University*
AlScN/GaN Multiple-Channel Field Effect Transistors

11:10 AM
[LN] TBD
Late News

11:20 AM
Junghun Koo *University of Minnesota*
ALD Dielectric Modulation Doping Enabled High-Performance Ultra-Wide Bandgap SrSnO₃ MOSFETs

11:40 AM **Lunch Break**

Wide Band Gap 5
Michigan League – Koessler Room, 3rd floor

2D and Memory
Michigan League – Room 4, 1st floor

1:00 PM
Hanqiao Zhang *Cornell University*
Silicon Nitride Passivated AlScN-Barrier High Electron Mobility Transistors Demonstrating Negligible Current Dispersion

1:00 PM
[INV] Moshe Ben Shalom *Tel Aviv University*
Sliding Ferroelectric Resonant Tunneling (SFERT) Junctions: A New Paradigm for Slidetronic Computing

1:20 PM
Md Azizul Hasan *NC State University*
First Demonstration of Vertical GaN MPS Diodes Obtained via Mg Implantation and Ultra-High Pressure Annealing

1:30 PM
[INV] Kaustuv Banerjee *imec*
Bridging Lab Scale Understanding and 300 mm Integration for Emerging Device Platforms

1:40 PM
[STU] Nabasindhu Das *Arizona State University*
Sub-Micron Gate beta-Ga₂O₃ FinFETs with Current Density > 700 mA/mm and ON/OFF Ratio > 10⁸

2:00 PM
[INV] Peng Zhou *Fudan University*
2D Digital Circuits with Atomic-Layer-Scale Radiation-Tolerance

2:00 PM
[LN] TBD
Late News

2:30 PM
[INV] Patrick Xiao *Sandia National Laboratories*
Designing, scaling, and benchmarking resistive and electrochemical memories for accurate analog AI inference

3:00 PM End of DRC 2026

Poster Session — Monday, June 22, 5:30 PM | Michigan League — Ballroom, 2nd floor

★ Posters #1–10 are nominees for the Best Student Poster Award

#	Presenter / Affiliation	Title
★ 1	Kyung Min Lee <i>Seoul National University, Republic of Korea</i>	Investigating Intermediate-State-Induced Write Error Rate Degradation in Magnetic Tunnel Junctions via Domain-Level Electrical Analysis
★ 2	Shisong Luo <i>Rice University, United States</i>	GaN p-Channel MOSFET with ALD Ga ₂ O ₃ Gate Dielectric Featuring a High BFOM (0.43 MW/cm ²) and over 200 V Blocking Capability
★ 3	Ashutosh Krishna Amaram <i>University of Illinois Chicago, United States</i>	Atomistic Insights into the Switching Mechanism and the Origin of Device-to-Device Variability in Ta-HfO ₂ -Pt based Memristive Device
★ 4	Xucheng Yang <i>NC State University, United States</i>	Experimental Design Parameter Exploration of Ultra-Low Threshold III-V/Si Quantum Dot Microring Lasers
★ 5	Jianming Huang <i>Southern University of Science and Technology, China</i>	Confining mobile ions for 40x transient NDR in ITO/HfO ₂ FETs with incomplete top gate metal coverage
★ 6	Shubham Babbar <i>Ben-Gurion University of the Negev, Israel</i>	Multiple biomarkers detection under a single drop of physiological solution using a field-effect transistor
★ 7	Sanjeev Khare <i>Purdue University, United States</i>	Octupole Transfer Torque and Spin-Orbit Torque Driven Oscillations and Switching in Cubic Chiral All-AFM Devices
★ 8	Debaditya Bhattacharya <i>Cornell University, United States</i>	High-current ultrawide-bandgap AlGaN pin diodes with low on-resistance and UVC emission
★ 9	Alexander Karl <i>TU Wien, Austria</i>	Physics-Based Modeling of Reliability, Stability, and Leakage in 2D MOSFETs
★ 10	Akshey Dhar <i>Cornell University, United States</i>	Enhancement Mode Operation of AlN XHEMTs
11	Kyota Mikami <i>Kyoto University, Japan</i>	Mobility Improvement in SiC MOSFETS by Shallow Counter Doping
12	Krishna Rudrapal <i>University of Stuttgart, Germany</i>	Low-Voltage Forming-Free, Abrupt, and Gradual Resistive Switching in Surface-Modified IGZO Memristors
13	Myungsoo Kim <i>UNIST, Republic of Korea</i>	Low-Noise and Hysteresis-Free MoS ₂ Transistors Enabled by High-k Single-Crystalline Rare-Earth Oxychloride Dielectrics
14	Alireza Moazzeni <i>Wayne State University, United States</i>	Identification of Cycle-to-Cycle Switching Regimes in Filamentary TaOx RRAM using Time Series Analysis
15	Soren Schafer <i>University of Stuttgart, Germany</i>	Aging of Unencapsulated Te Transistors in Ambient Air and Comparison of Annealing Conditions
16	Sara Ghazvini <i>University of Texas at Dallas, United States</i>	High-Speed, Low-Voltage Ge/Si APDs Optimized with Bayesian Optimization and TCAD for CMOS Integration
17	Haixin Zhao <i>University of Delaware, United States</i>	Phase Reconfigurability-enhanced Metasurface Image Compression with an Integrated Photonic Encoder
18	Showmik Singha <i>University of Missouri-Columbia, United States</i>	Machine Learning Enabled Parameter Extraction of beta-Ga ₂ O ₃ MOSFETs
19	VENKATESWARLU GADDAM <i>University of Florida, United States</i>	Hybrid Epitaxial/Textured AlN Seed Layer Impact on Ferroelectric Al _{0.7} Sc _{0.3} N Memory Devices
20	Xin Su <i>Penn State University, United States</i>	Noise and Drift Models for Electrochemical Memory (ECRAM)
21	Md Rahatul Islam Udoy <i>University of Tennessee Knoxville, United States</i>	High Temperature 1T1R Memory Using Ferroelectric Diode and GaN Transistor
22	Dimitrios Spithouris <i>Forschungszentrum Juelich, Germany</i>	Volatile amorphous SrTiO ₃ -based memristive devices with tunable temporal dynamics for event-based sensing
23	Md Sazzadur Rahman <i>Duke University, United States</i>	Unconventional BTI in ITO FETs: Thickness-Tuned Temperature-Induced Polarity Reversal
24	Asmita Thool <i>IIT Madras, India</i>	Non-filamentary resistance switching in CVD-MoS ₂ memristive devices
25	Katherina Loske <i>University of Florida, United States</i>	13.5 kV NiO/beta-Ga ₂ O ₃ Heterojunction Rectifiers on 4-Inch Wafers with Dielectric-Assisted Field-Plate Edge Termination
26	Arka Chakraborty <i>IIT Kanpur, India</i>	Cryogenic Compatible Temperature Responsive Model of Vertical InAs/InGaAs GAA Nanowire Ferroelectric FET for Neuromorphic Applications

#	Presenter / Affiliation	Title
27	ARPAN GHOSH <i>Penn State University, United States</i>	Light-induced giant random telegraph noise in CuScP2S6/MoS2 heterostructures and their use in noise resilience image inference
28	Nihal Raut <i>IIT Bombay, India</i>	Self-Adaptive Hybrid CMOS-FeCAP Image Sensor for Dynamic Range Enhancement
29	Fevronia Andreou <i>Texas A&M; University, United States</i>	Performance and Energy Efficiency Enhancement in HfO2-Based ReRAMs via Mo Doping
30	Jianan Song <i>Penn State University, United States</i>	Study of leakage current in GaN junction field-effect transistor under heavy ion radiation
31	Jianming Huang <i>Southern University of Science and Technology, China</i>	Mobile-ion-induced transient NDR in emerging FETs: Optimization insights and figures of merit via compact modeling
32	Shicheng Su <i>KAUST, Saudi Arabia</i>	In-sensor learning via microfluidic neuromorphic charge-trapping memory
33	Shayan Parhizkar <i>AMO GmbH / RWTH Aachen University, Germany</i>	Wafer-Scale Waveguide-Integrated Graphene-based Optoelectronic Mixers
34	Sooyeol Bae <i>KAIST, Republic of Korea</i>	A Physics-Based Analytical Threshold Voltage Model of Oxide Semiconductor Governed by Depletion Width
35	Mayuri Sritharan <i>University of Waterloo, Canada</i>	Emulating Neuron and Synaptic Functions through Antiferroelectric Tunnel Junctions: A Novel Dynamic Simulation Approach
36	MD YASIR BASHIR <i>IIT Kanpur, India</i>	Highly Scalable Multi-Bit Monolithic Stackable 3D Dynamic Random-Access Memory Cell
37	Nolan Hendricks <i>Air Force Research Laboratory, United States</i>	DC and RF Performance of GaN MISHEMTs with High-kappa AlTiO Nanolaminate Gate Dielectric
38	Cesely Smith <i>Carnegie Mellon University, United States</i>	Contact Engineering of Foundry n-Type CNFETs with Al Contacts
39	Parthiban Santhanam <i>UCLA, United States</i>	Chip-Scale Optoelectronic Voltage Boost Converters
40	Sung-Kun Park <i>SK hynix, Republic of Korea</i>	Evolution of single-poly embedded NVM for low-density code storage EEPROM
41	Md Arifuzzaman Faisal <i>University of Michigan, United States</i>	Exact field Solution of Contact Resistance in Anisotropic 2D Transistors with Experimental Benchmarking
42	Atul Sachan <i>IIT Bombay, India</i>	Field-Assisted Charge Trapping in ALPO-IGZTO TFTs Enabling High Endurance and Long-Term Retention Without Tunneling and Blocking Layer
43	Jiahui Yang <i>Duke University, United States</i>	Record Switching Speed of 100 ns in Interfacial Memristors with High Uniformity
44	Ram Munde <i>Purdue University, United States</i>	Nanoscale Thermal Resistance Mapping of Nanocrystalline Cu Thin Films Using Scanning Thermal Microscopy with Hertzian Contact Geometric Correction
45	Dawei Wang <i>Arizona State University, United States</i>	GaN Vertical Trench MOSFET Using Stepped Power Slanted RIE Polish
46	Michiel van Setten <i>imec, Belgium</i>	Atomistic modeling of fluorine doping in IGZO
47	Jeelka Solanki <i>University at Albany, United States</i>	In-Memory Image Processing Using 65nm CMOS-integrated 1T-1R RRAM Arrays
48	Abdul Momin Syed <i>KAUST, Saudi Arabia</i>	A Highly Stable Multimodal Perovskite Heterojunction Memristor Enabling In-Memory Perception
49	Xiaojun Zheng <i>Penn State University, United States</i>	High Temperature Switching in ALD-Grown Ferroelectric AlN Thin-Film Transistors with ZnO Channel
50	Riya Rajpurohit <i>University of Virginia, United States</i>	Atom to System Model for a Superconducting Non-volatile Memory Device
51	Abhrajit Roy <i>IIT Bombay, India</i>	Solution-Processed Ti-Pt/NiO/Ag Non-Volatile Devices as Synapses and Neurons in Analog Spiking Neural Network Hardware